This is an Accepted Manuscript, which has been through the Royal Society of Chemistry peer review process and has been accepted for publication.

Accepted Manuscripts are published online shortly after acceptance, before technical editing, formatting and proof reading. Using this free service, authors can make their results available to the community, in citable form, before we publish the edited article. We will replace this Accepted Manuscript with the edited and formatted Advance Article as soon as it is available.

You can find more information about Accepted Manuscripts in the Information for Authors.

Please note that technical editing may introduce minor changes to the text and/or graphics, which may alter content. The journal’s standard Terms & Conditions and the Ethical guidelines still apply. In no event shall the Royal Society of Chemistry be held responsible for any errors or omissions in this Accepted Manuscript or any consequences arising from the use of any information it contains.
CO gas sensing properties of direct-patternable SnO$_2$ films containing graphene or Ag nanoparticles

Hyuncheol Kim, Chang-Sun Park, Kyung-Mun Kang, Min-Hee Hong, Yong-June Choi, Hyung-Ho Park*

The gas sensing properties of direct-patternable SnO$_2$ thin films prepared by photochemical solution deposition were improved by an incorporation of graphene or Ag nanoparticles. The CO gas sensitivity of the SnO$_2$ thin film was 3.65, but increased to 6.84 and 18.06 with graphene and Ag nanoparticles incorporation, respectively. Direct-patterning of graphene or Ag nanoparticles incorporated SnO$_2$ thin films can be performed to a 40 µm scale pattern without a photosensit or etching process.

Introduction

Tin dioxide (SnO$_2$) thin films have been increasingly studied as transparent electrode materials for display devices and anode materials for gas sensors due to the high optical transparency, high chemical durability, and low cost.$^{1,4}$ Gas sensors based on a metal oxide semiconductor have attracted considerable attention because of their low cost, high sensitivity, and high compatibility with microelectronic processing. CO gas detection can be attributed to a surface reaction, which occurs at lower temperatures ($< 500^\circ$C).$^5$ When O$_2$ molecules are adsorbed to the surface of a SnO$_2$ thin film, they trap the electrons in the form of ions. Alternatively, when a gas sensor is exposed to CO gas, CO is oxidized by O$^-$ and releases electrons to the surface. O$^-$ is believed to become dominant at operating temperatures of 300-450°C.$^6$

There have been many efforts to modify and improve the material properties by the applied nanostructure and the addition of nanosized materials.$^{7,8}$ Ag nanoparticles have been widely used in gas sensor applications and their incorporation into materials basically relies on the ability in acting either as electron sink or redox catalyst.$^9,10$ Furthermore Ag metal dopant in SnO$_2$ gas sensor has been reported acting with a catalytic effect. The metal additive acts as a catalyst to modify the surface reactions of metal oxide semiconductors toward sensing gases.$^{11}$ In particular, it is reported that the noble metal acts as a strong acceptor of electrons and remove electrons from the oxide. So, the metal oxide has large response.$^{12}$ Graphene has very high mobility ($\sim$200,000 cm$^2$/Vs) with π-bonding on the surface and good potential for detecting gases due to their large surface area resulting from a large aspect ratio and outer walls.$^{13,14}$ Also, the graphene has been reported that the potential barrier of oxide could be changed by making the hetero-junctions at the interface of oxide. Therefore, an improvement in the sensor response in the case of hybrid graphene–oxide was expected.$^{15}$

A micro-patterning process is commonly used for the fabrication of gas sensor devices.$^{16}$ The conventional etching process is accompanied by the generation of physical defects and the resulting degradation of properties, pollution from hazardous materials, and additional outcomes. Photoresists and etching are not necessary when using photochemical solution deposition because the coated films behave like a negative photoresist. As a result, damage and problems from conventional etching can be avoided.$^{17}$

The effects of graphene or Ag nanoparticles on the gas sensing properties of SnO$_2$ thin films were investigated in this study. The gas sensitivity of SnO$_2$ sensors was improved through incorporation of graphene or Ag nanoparticles. Furthermore, direct-patterning of SnO$_2$ thin films containing graphene or Ag nanoparticles was achieved using a photosensitive solution and ultra violet (UV) light exposure to avoid damage from dry etching and simplify the micro-scaled patterning procedure.

Results and discussion

The direct-patterning of SnO$_2$ thin film containing graphene or Ag nanoparticles was examined by removing the area not exposed to UV using 4-methyl-2-pentanone. In the scanning electron microscopy (SEM) image of Figure 1, the relatively bright area corresponds to the SnO$_2$ thin film with incorporated Ag nanoparticles and the dark area is the Si substrate. As shown at the pattern edge, patterning at a scale of several tens of microns was successfully obtained by lithography using photochemical solution deposition. The graphene-incorporated, SnO$_2$ thin film also showed the same behavior.
Figure 1. SEM image of SnO$_2$ thin film with incorporated direct-patterned Ag nanoparticles annealed at 500°C.

X-ray diffraction patterns of SnO$_2$ thin films containing graphene or Ag nanoparticles annealed at 500°C are presented in Figure 2. The diffraction patterns were indexed as (110), (101), (200), (211), and (220) peaks of the cassiterite crystalline SnO$_2$ phase.\textsuperscript{18} Similar diffraction patterns were observed after the incorporation of graphene or Ag nanoparticles. The presence of graphene or Ag nanoparticles did not significantly affect the phase formation of SnO$_2$, but the diffraction pattern intensity decreased due to the degraded crystalline state of SnO$_2$ with graphene or Ag nanoparticles compared to the pristine SnO$_2$. The presence of graphene or Ag nanoparticles potentially increased the impurity content in the SnO$_2$ thin films and may act as a grain growth inhibitor.

The surface morphology change of the SnO$_2$ according to the addition of Ag nanoparticles and graphene was analyzed using AFM, and the results are presented in Fig. 3. As shown in Figure 3, the surface roughness of the graphene-incorporated SnO$_2$ thin film was approximately 3.7 times greater than that of the pristine SnO$_2$ thin film. The AFM results conclude that the bumps were formed by graphene incorporation and they increased the surface area of the films. The larger surface area allows more gas molecules to be absorbed to the surface of the sensing film.

Figure 2. XRD patterns of pristine SnO$_2$ and SnO$_2$ hybrid films annealed at 500°C with 0.0055 wt.% Ag nanoparticles and 0.05 wt.% graphene.

The chemical bonding states of SnO$_2$ thin films containing graphene or Ag nanoparticles were examined using XPS to investigate the change of chemical bonding states. The films were prepared by annealing at 450°C for 12 h under air (oxidation) and vacuum (reduction) ambient. C 1s, O 1s, Sn 3d, and Ag 3d core levels were obtained and the results of O 1s and Sn 3d are given in Figure 4. However Ag 3d$_{5/2}$ peak was not observed due to an undetectable small amount of Ag NPs in SnO$_2$ film.\textsuperscript{19} In C 1s spectrum of SnO$_2$ thin film containing graphene, no extra peak contribution from graphene was observed due to its small amount as the case of Ag NPs or almost same binding energy between graphene and air contaminated hydrocarbon.\textsuperscript{20,21} The binding energies of the core level were corrected using the reference C 1s peaks at 284.5 eV.\textsuperscript{22} Changes in the core level spectra of Sn 3d and O 1s would indicate a formation of SnO$_2$ between Sn and O atoms. As shown in Figure 4a, the binding energy of the O-Sn bond in the films annealed at air ambient was the same.
Figure 4. XPS spectra of (a) O 1s and (b) Sn 3d core levels of pristine SnO$_2$ and SnO$_2$ hybrid films with 0.0055 wt.% Ag nanoparticles and 0.05 wt.% graphene after annealing at 450°C under air and vacuum ambient.

However, in the case of the films annealed at vacuum ambient, the binding energy of the SnO$_2$ thin film containing Ag nanoparticles was less than those of the pristine SnO$_2$ and graphene-incorporated SnO$_2$ thin films.

Additionally, as shown in Figure 4b, the binding energy of the Sn 3d core level spectra exhibited similar behavior to those of the O 1s spectra. Based on these results, the x of SnO$_{2-x}$ increased by incorporation of the Ag nanoparticles. Usually, noble metals inject electrons in the conduction band of the metal oxide by changing the oxidation state of noble metal as per following reaction:

$$\text{metal}^{y+} + x\text{VO}^• \rightarrow \text{metal}^{(y-x)+} + x\text{VO}^{•+}$$

Where VO$^•$ the singly ionized oxygen vacancy, and VO$^{•+}$ is the doubly ionized oxygen vacancy. Therefore, the film was more reduced and the oxygen vacancies increased. Nonstoichiometric SnO$_2$ can be characterized with oxygen vacancies, which are a cause of the conduction mechanism in SnO$_2$.24, 25

Hence the gas sensing analyses were carried out to clarify the effect of changed surface area and state of SnO$_2$ due to the Ag nanoparticles and graphene, and the results are given in Fig. 5. During exposure to 100 ppm CO at 400°C, the sensor resistance decreased, which indicates that the SnO$_2$ thin films were an n-type semiconductor sensor. From the difference between the sensor resistance in air ($R_{\text{air}}$) and the sensor resistance in CO ($R_{\text{CO}}$), the sensitivity of the sensors (sensitivity = $R_{\text{air}} / R_{\text{CO}}$) can be predicted.26 The sensitivity of the SnO$_2$ sensor with incorporated nanostructure (graphene or Ag nanoparticles) was greater than that of the pristine SnO$_2$ sensor because the difference between $R_{\text{air}}$ and $R_{\text{CO}}$ increased compared to the pristine SnO$_2$ sensor, as shown in Figure 6a. Sensing properties, such as sensitivity, 90% response time, and 90% recovery time of the nanostructure-incorporated SnO$_2$ sensor, were shown in Figure 6b and measured as 3.65, 10.04, and 7.04 s, respectively. The sensitivities of the SnO$_2$ containing graphene or Ag nanoparticles sensors increased to 6.84 or 18.06, respectively.

Figure 5. Transient response of (a) pristine SnO$_2$, (b) SnO$_2$ with incorporated Ag nanoparticles, and (c) graphene-incorporated SnO$_2$ thin film sensor containing Ag nanoparticles and graphene measured at 400°C with 100 ppm CO gas.

Figure 6. (a) Sensor resistance of nanostructure-incorporated SnO$_2$ sensor in dry air and 100 ppm CO balanced with dry N$_2$, (b) sensitivity (■), 90% response time (♦), and 90% recovery time (●) of nanostructure-incorporated SnO$_2$ sensors measured at 400°C in dry air and 100 ppm CO balanced with dry N$_2$. 
SnO$_2$ thin films have lower $R_{\text{CO}}$ and higher $R_{\text{air}}$ as they were oxidized in air and reduced in CO gas. The $R_{\text{CO}}$ of sensors containing graphene or Ag nanoparticles decreased more than a pristine SnO$_2$ sensor. Ag nanoparticles and graphene decreased resistivity of the SnO$_2$ thin films as shown in previous works.$^{27,28}$ When the air flowed, SnO$_2$ thin film was oxidized by the oxygen in air and the resistance increased. Although the nanostructure-incorporated SnO$_2$ sensor was also oxidized, the difference between $R_{\text{CO}}$ and $R_{\text{air}}$ increased more than those of the pristine SnO$_2$ sensor. This difference was due to the surface area increased by the graphene or oxygen vacancies formed by the Ag nanoparticles. The general gas sensing model is based on modulation of the depletion layer by oxygen absorption. In general, an incorporation of graphene induces an increase of electrical conductivity of metal oxides due to an enhancement of carrier mobility. However if the graphene exist on the surface, it will enhance the specific surface area and change the potential barrier of oxide.$^{13,14}$ This is because in case of synthesis of material using solution process, the metal oxide will be wrapped with graphene on surface of interior oxide. As a result, the graphene has a large surface to volume ratio and the surface area of the film increased depending on graphene incorporation.$^{29}$ As an above effect, the graphene increases the absorption of oxygen ion and also the ratio of change of resistance of metal oxide. Therefore, the sensitivity of the graphene-incorporated SnO$_2$ sensor was increased despite low $R_{\text{air}}$. Ag nanoparticles generated oxygen vacancies in the SnO$_2$ matrix and the oxygen vacancies acts as reaction sites for oxygen in air.$^{30,31}$ As a result, the $R_{\text{air}}$ of SnO$_2$ sensor with incorporated Ag nanoparticles increased similarly to those of the pristine SnO$_2$ sensor. With the decreased $R_{\text{CO}}$ and similar $R_{\text{air}}$, the SnO$_2$ sensor with incorporated Ag nanoparticles has more sensitivity than the pristine SnO$_2$ and graphene-incorporated SnO$_2$ sensors. Because the sensor resistance changed due to the increase in electron concentration resulting from the oxidation and reduction reactions facilitated by the reaction gas, the response and recovery time increased with an increase in the difference between $R_{\text{air}}$ and $R_{\text{CO}}$. The increased response and recovery time would be expected for a sensor with highly fluctuating resistance, however, as shown in Figure 6b, the response and recovery times of the SnO$_2$ sensor with incorporated Ag nanoparticles were similar to the graphene-incorporated SnO$_2$ sensor despite a large difference in the sensitivity. Oxygen in air reacted easily on the SnO$_2$ matrix in the SnO$_2$ sensor with incorporated Ag nanoparticles due to the oxygen vacancies formed by the Ag nanoparticles. From these reasons, oxidation and reduction occurring on the surface increased, making the movement of the surface electrons quite rapid. As a result, the sensitivity increase in the SnO$_2$ sensor from oxygen vacancies for reduction and oxidation by Ag nanoparticle incorporation was more important than that from the larger surface area by graphene incorporation.

Conclusions

The CO gas-sensing behavior of a SnO$_2$ gas sensor with graphene or Ag nanoparticles incorporation was investigated. The presence of graphene or Ag nanoparticles does not affect the phase formation of SnO$_2$ films, but the film crystallinity was slightly degraded with the incorporation. The CO gas sensitivity was enhanced by the incorporation of Ag nanoparticles or graphene into the SnO$_2$ sensor. Graphene in the SnO$_2$ sensor increased sensitivity by increasing the surface area. However, the SnO$_2$ sensor with Ag nanoparticles showed increased sensitivity than that of the graphene incorporation because oxygen vacancies formed by Ag nanoparticles act as reaction sites for reduction and oxidation by oxygen.

Experimental

The photosensitive precursor for the production of SnO$_2$ films was tin 2-ethylhexanoate, Sn(O$_2$CCH(C$_2$H$_5$)$_2$). The solvent and sol stabilizer were 4-methyl-2-pentanone and monoethanolamine, respectively. Tin 2-ethylhexanoate was dissolved in 4-methyl-2-pentanone at 0.3 M and monoethanolamine was added for stabilization at a molar ratio of 1.0. The dissolved photosensitive solution was stirred at room temperature. Ag nanoparticles were prepared by spontaneous reduction of Ag 2-ethylhexanoate in a dimethyl sulfoxide solvent. The concentration of Ag 2-ethylhexanoate was $1 \times 10^{-4}$ M and trisodium citrate was used as a capping agent for formation of size-controlled Ag nanoparticles.$^{32}$ Graphene (AO-2, Graphene Supermarket) was used as a graphene source. Graphene in the mixed solution was dispersed by a sonicator.$^{33}$ To obtain SnO$_2$ thin films containing graphene or Ag nanoparticles, a 0.05 wt.% graphene or 0.0055 wt.% Ag nanoparticles dispersed solution was added to the SnO$_2$ photosensitive solution. The graphene and Ag nanoparticles contents were selected by considering the atomic weight and percolation effect from previous works.$^{27,28}$ The solution was spin-coated at 2,000 rpm for 30 s on glass and Si substrates with Pt-interdigitated electrodes (IDE). For direct-patternning, the spin-coated film was exposed to 365-nm wavelength UV light. The UV exposed films were then washed with 4-methyl-2-pentanone to remove the unexposed area of the film. After washing, the films were aged at 50°C for 12 h in a dry oven and annealed at 500°C for 1 h in a tubular furnace under an O$_2$ atmosphere to remove the solvent and organic residues. Finally, the films were annealed in a vacuum furnace at 450°C for 12 h.

A sensor for CO gas was fabricated using a SiO$_2$/Si substrate with Pt IDE in which the gap between each electrode was 5 µm. The thickness of the Pt was 200 nm and the IDE patterns were fabricated using photolithography and dry etching. The responses of the fabricated gas sensors to CO gas were measured at 400°C by monitoring the change in sensor resistances while changing the flow gas from dry N$_2$ to test gases (100 ppm CO balanced with dry N$_2$). To eliminate interfering effects, a constant flow rate of 1000 sccm for the dry air and test gases was used. The film resistance was measured under a DC bias voltage of 3 V using a source measurement...
unit (Keithley 2635A). The crystallinity was analyzed by an X-ray diffractometer (XRD, D/MA-2000, Rigaku) with Cu Kα radiation. The surface roughness and morphology of the films were analyzed in non-contact mode by atomic force microscopy (AFM, XE-100, Park Systems) with a baseline noise of 0.01 nm. X-ray photoelectron spectroscopy (XPS, K-Alpha, Thermo Scientific) was used with a monochromated Al Kα source to investigate the surface chemical bonding state of the films. The accelerating voltage and emission current of the X-ray source were 15 kV and 20 mA, respectively.

Acknowledgements

This work was supported by a National Research Foundation of Korea (NRF) grant funded by the Korean government (MEST) (No. 2012R1A2A2A01011014).

Notes and references

Department of Materials Science and Engineering, Yonsei University, 50 Yonsei-ro, Seodaemun-gu, Seoul 120-874, Republic of Korea Fax: +82328655178; E-mail: hpark@yonsei.ac.kr (H.-H. Park)